

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.	:	10/791,763
Applicant	:	Wolfgang Dettmann et al.
Confirmation No.	:	4420
Filed	:	March 4, 2004
TC/A.U.	:	1795
Examiner	:	Ruggles, John S.
Customer No.	:	71737
Docket No.	:	3000.0036C
Title	:	Set of at Least Two Masks for the Projection of Structure Patterns and Method for Producing the Masks

MAIL STOP AF

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

AMENDMENT ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION
AND
RESPONSE TO NOTICE OF NON-COMPLIANT AMENDMENT

Sir:

In response to the final Office Action mailed September 14, 2007, and the Advisory Action and Notice of Non-Compliant Amendment mailed December 20, 2007, please amend the above-identified application as follows:

Amendments to the Specification: None.

Amendments to the Claims: reflected in the listing of claims, which begins on page 2 of this paper.

Remarks: begin on page 4 of this paper.